

Press Release

P.S.T. AND DYNAMIC ENGINEERING ENTER INTO STRATEGIC TECHNICAL AND MARKETING ALLIANCE

Leading polysilicon process technology companies join forces to provide comprehensive solutions

Houston, TX and Mesa, AZ – March 17, 2010 - Dynamic Engineering (DEI), a leading engineering firm in chemical production technologies for chlorosilane, polysilicon and silane, announced their strategic alliance with Polycrystalline Silicon Technology Corporation (P.S.T.).

Prior to this agreement, the majority of DEI's TCS reactor licenses have been based on Chlorination Technology. DEI now offers P.S.T.'s advanced Hydrochlorination technology as well as, the fully closed-loop chlorosilane and silane technology. While both technologies are broadly used in the Polysilicon Industry, in some scenarios Hydrochlorination can offer lower capital investment and operating costs due to the more efficient chemical conversion of STC versus thermal conversion. DEI is leading the marketing and sales of the technology, managing the creation of the full basic engineering design packages, and is responsible for the manufacture and sale of key process equipment. "By creating an alliance between P.S.T. and DEI we have effectively given the Polysilicon market the best of either Chlorosilane or Hydrochlorination solutions for Poly production," said Kevin Drumm, Vice President Business Development at DEI.

The combination of P.S.T.'s hydrochlorination of silicontetrachloride to trichlorosilane technology and DEI's technologies for maximizing yield and TCS purity provides the Polysilicon Industry with the most cost effective and integrated solutions to polysilicon manufacturing available today. Additionally, DEI assists clients in the selection of reactors and is responsible for the integration of the CVD reactors into a P.S.T. completely closed loop Polysilicon Plant, based on either TCS or Silane. "The full plant integration by DEI and P.S.T. provides for the optimization of state-of-the-art polysilicon plant design to minimize installed costs, maximize yields and minimize waste streams," remarked Leo Rogers, President of P.S.T.

"Dynamic Engineering has a 25 year history of bringing the most effective processes to leading chemical companies and is pleased to join with P.S.T.'s 45 year history of polysilicon experience. With the combined DEI and P.S.T. experience and technologies, we anticipate accelerated growth in both existing and adjacent market segments over the coming years. At this time, we are also exploring synergistic technologies that can bring further process improvements to the Polysilicon industry while minimizing capital investment," states Joseph Ausikaitis, President and CEO of Dynamic Engineering.

About DEI

Dynamic Engineering, Inc. is an engineering company focused on the Chemical and Pharmaceutical Industries. DEI has built an experienced team dedicated to design of silane and trichlorosilane synthesis and purification processes for polysilicon production used in the solar and semiconductor industries. DEI is a leader in its field with over a 25-year track record of successful projects. Dynamic Engineering, Inc. is headquartered in Houston, TX with offices in Sturgis, MI and Shanghai, P.R.C. To learn more, visit www.dynamicengineer.com

Press Release

About P.S.T.

P.S.T., founded in 1980, is headquartered in Arizona, U.S.A. P.S.T. has designed, engineered, and constructed three Polycrystalline plants and has over 300,000 hours of plant operating experience. Design experience includes over five years of production experience in the hydrochlorination of silicon tetrachloride to Trichlorosilane. Today, P.S.T. is a silicon technology licensing company that offers the most advanced designs for the chemical portion of Polycrystalline Silicon plants. For more information, visit www.pst-pst.com

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